

## Erratum to: Strategies to obtain pattern fidelity in nanowire growth from large-area surfaces patterned using nanoimprint lithography

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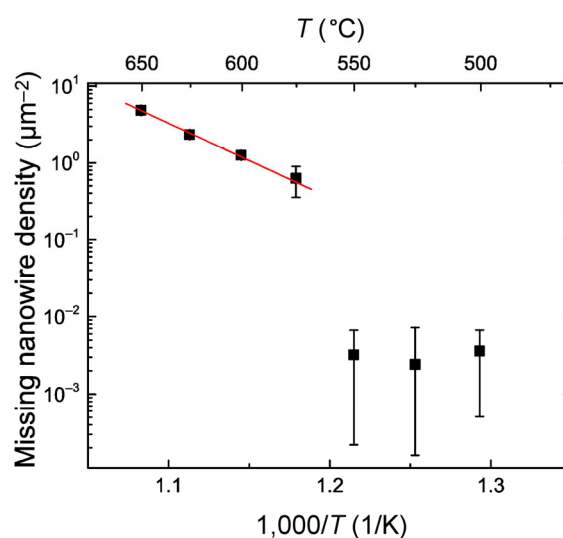
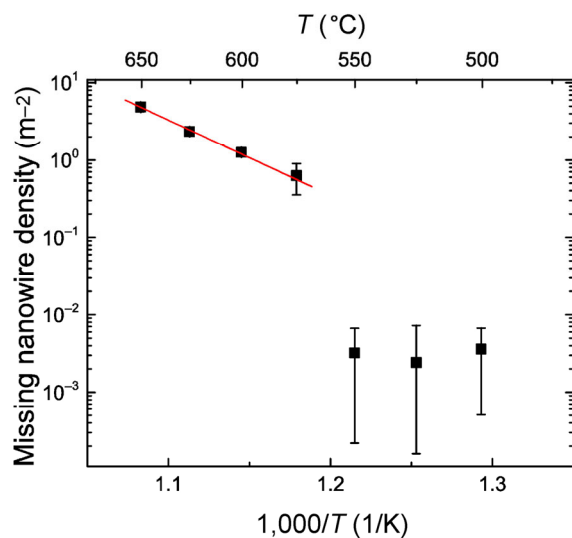
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### Erratum to

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The unit of  $y$  axis in Fig. 2 in the original version of this article was unfortunately wrongly written on page 2856, instead of  $\text{m}^{-2}$ .

It should read  $\mu\text{m}^{-2}$ .



The online version of the original article can be found at  
<http://dx.doi.org/10.1007/s12274-016-1165-z>

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